

UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P. De 1450 Alexandria, Virginia 22313-1450 www.uspio.gov

| APPLICATION NO. | FILING DATE | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO. | CONFIRMATION NO |
|---|-----------------|----------------------|-------------------------|-----------------|
| 09/862,827 | 05/22/2001 | Jack A. Mandelman | FIS920000224US2(13814A) | 9621 |
| 7 | 7590 07/14/2003 | | | |
| SCULLY, SCOTT, MURPHY & PRESSER 400 Garden City Plaza Garden City, NY 11530 | | | EXAMINER | |
| | | | LEWIS, MONICA | |
| | | | ART UNIT | PAPER NUMBER |
| | | | 2822 | |
| • | | | DATE MAILED: 07/14/2003 | |

Please find below and/or attached an Office communication concerning this application or proceeding.

| | | m | | | | |
|---|--|--|--|--|--|--|
| | Application No. | Applicant(s) | | | | |
| Office Action Summany | 09/862,827 | MANDELMAN ET AL. | | | | |
| Office Action Summary | Examiner | Art Unit | | | | |
| The MAII INC DATE of this communication and | Monica Lewis | 2822 | | | | |
| The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply | | | | | | |
| A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.1: after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period of - Failure to reply within the set or extended period for reply will, by statute - Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b). Status | 36(a). In no event, however, may a reply be ting within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE | mely filed ys will be considered timely. In the mailing date of this communication. ED (35 U.S.C. § 133). | | | | |
| 1) Responsive to communication(s) filed on 29 A | A <i>pril 2003</i> . | | | | | |
| 2a) ☐ This action is FINAL . 2b) ☑ Th | is action is non-final. | | | | | |
| 3) Since this application is in condition for allows closed in accordance with the practice under Disposition of Claims | | | | | | |
| 4)⊠ Claim(s) <u>53-59</u> is/are pending in the application | n. | / | | | | |
| 4a) Of the above claim(s) is/are withdraw | | | | | | |
| 5) Claim(s) is/are allowed. | | | | | | |
| 6)⊠ Claim(s) <u>53-59</u> is/are rejected. | | | | | | |
| 7) Claim(s) is/are objected to. | | | | | | |
| 8) Claim(s) are subject to restriction and/o | r election requirement. | | | | | |
| Application Papers | | | | | | |
| 9)☐ The specification is objected to by the Examine | | | | | | |
| 10)⊠ The drawing(s) filed on <u>15 August 2001</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner. | | | | | | |
| Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). | | | | | | |
| 11) The proposed drawing correction filed on is: a) approved b) disapproved by the Examiner. If approved, corrected drawings are required in reply to this Office action. | | | | | | |
| 12) The oath or declaration is objected to by the Examiner. | | | | | | |
| Priority under 35 U.S.C. §§ 119 and 120 | | | | | | |
| 13) Acknowledgment is made of a claim for foreign | n priority under 35 U.S.C. & 1196 | a)-(d) or (f) | | | | |
| a) ☐ All b) ☐ Some * c) ☐ None of: | priority and or or or or or or | -/ (u/ o. (·/· | | | | |
| 1.☐ Certified copies of the priority document | s have been received. | | | | | |
| 2. Certified copies of the priority documents have been received in Application No | | | | | | |
| Copies of the certified copies of the prio application from the International Bu | rity documents have been receiv reau (PCT Rule 17.2(a)). | ed in this National Stage | | | | |
| * See the attached detailed Office action for a list of the certified copies not received. 14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application). | | | | | | |
| a) The translation of the foreign language provisional application has been received. | | | | | | |
| 15) Acknowledgment is made of a claim for domest | • • | | | | | |
| Attachment(s) | _ | | | | | |
| Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449) Paper No(s) | 5) 🔲 Notice of Informal | ry (PTO-413) Paper No(s) Patent Application (PTO-152) | | | | |

Application/Control Number: 09/862,827 Page 2

Art Unit: 2822

DETAILED ACTION

1. This office action is in response to the amendment filed April 29, 2003.

Response to Arguments

2. Applicant's arguments with respect to claims 53-59 have been considered but are moot in view of the new ground(s) of rejection.

Specification

3. The lengthy specification has not been checked to the extent necessary to determine the presence of all possible minor errors. Applicant's cooperation is requested in correcting any errors of which applicant may become aware in the specification.

Claim Rejections - 35 USC § 103

- 4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 5. Claims 53-56 are rejected under 35 U.S.C. 103(a) as obvious over Schrems et al. (U.S. Patent No. 5,945,704) in view of Gambino (U.S. Patent No. 6,174,756) and Ajit et al. (U.S. Patent No. 5,474,946).

In regards to claim 53, Schrems et al. ("Schrems") discloses the following:

- a) at least one array region (For Example: See Figure 1 and Column 3 Lines 28-33); and
 - b) an isolation region (For Example: See Figure 1 and Column 3 Lines 28-33).

Art Unit: 2822

In regards to claim 53, Schrems fails to disclose the following:

a) support region.

However, Gambino et al. ("Gambino") discloses a support region (For Example: See Column 2 Lines 22-38). It would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the semiconductor device of Schrems to include a support region as disclosed in Gambino because it aids in providing an efficient formation of an integrated circuit (For Example: See Column 1 Lines 65 and 66 and Column 2 Lines 1-11).

Additionally, since Schrems and Gambino are both from the same field of endeavor, the purpose disclosed by Gambino would have been recognized in the pertinent art of Schrems.

b) at least a gate conductor guard ring formed around said array region on top of said isolation region, wherein said gate conductor guard ring prevents trapping of a stringer of gate conductor polysilicon on said isolation region.

However, Ajit et al. ("Ajit") discloses a guard ring formed around said array region (For Example: See Figure 6). It would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the semiconductor device of Schrems to include a guard ring formed around said array region as disclosed in Ajit because it aids in reducing the number of masks and defects (For Example: See Column 1 Lines 10-67 and Column 2 Lines 1-20).

Additionally, since Schrems and Ajit are both from the same field of endeavor, the purpose disclosed by Ajit would have been recognized in the pertinent art of Schrems.

In regards to claim 54, Schrems discloses the following:

a) array region includes a plurality of DRAM cells embedded in a semiconductor substrate (For Example: See Figure 1 and Column 3 Lines 28-30).

Art Unit: 2822

In regards to claim 55, Schrems discloses the following:

a) wordlines (120) overlay each of said DRAM cells and a bitline (185) overlays said wordlines (For Example: See Figure 3).

In regards to claim 56, Schrems discloses the following:

- a) each of said DRAM cells are vertical DRAMs (For Example: See Figure 1).
- 6. Claims 57-59 are rejected under 35 U.S.C. 103(a) as obvious over Schrems et al. (U.S. Patent No. 5,945,704) in view of Gambino (U.S. Patent No. 6,174,756) and Bronner et al. (U.S. Patent No. 5,525,531).

In regards to claim 57, Schrems discloses the following:

- a) at least one array region having at least one wordline formed therein (For Example: See Figure 1 and Column 3 Lines 28-33); and
 - b) an isolation region (For Example: See Figure 1 and Column 3 Lines 28-33).

 In regards to claim 57, Schrems fails to disclose the following:
 - a) one support region having a local interconnect formed therein.

However, Gambino discloses a support region with an interconnect (For Example: See Figure 1A). It would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the semiconductor device of Schrems to include a support region with an interconnect as disclosed in Gambino because it aids in providing an efficient formation of an integrated circuit (For Example: See Column 1 Lines 65 and 66 and Column 2 Lines 1-11).

Additionally, since Schrems and Gambino are both from the same field of endeavor, the purpose disclosed by Gambino would have been recognized in the pertinent art of Schrems.

b) at least one wordline and said local interconnect are comprised of identical material.

Art Unit: 2822

However, Bronner et al. ("Bronner") discloses a wordlines and interconnects made of the same material (For Example: See Column 3 Lines 44-67). It would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the semiconductor device of Schrems to include wordlines and interconnects made of the same material as disclosed in Bronner because it aids in providing low capacitance (For Example: See Column 1 Lines 5-18).

Additionally, since Schrems and Bronner are both from the same field of endeavor, the purpose disclosed by Bronner would have been recognized in the pertinent art of Schrems.

In regards to claim 58, Schrems discloses the following:

a) array region includes a plurality of DRAM cells embedded in a semiconductor substrate (For Example: See Figure 1 and Column 3 Lines 28-30).

In regards to claim 59, Schrems discloses the following:

a) each of said DRAM cells are vertical DRAMs (For Example: See Figure 1).

Conclusion

7. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Monica Lewis whose telephone number is 703-305-3743.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Amir Zarabian can be reached on 703-308-4905. The fax phone number for the organization where this application or proceeding is assigned is 703-308-7722 for regular and after final

Art Unit: 2822

Page 6

communications. Any inquiry of a general nature or relating to the status of this application or

proceeding should be directed to the receptionist whose telephone number is 703-308-0956.

ML

July 7, 2003

AMIR ZARAJSIAN

SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 2800